

Nanocrystalline Co-P-SiC Electrocomposite Coating for Replacement of Hard Chrome

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Report Documentation Page				Form Approved OMB No. 0704-0188	
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1. REPORT DATE JAN 2006		2. REPORT TYPE		3. DATES COVERED 00-00-2006 to 00-00-2006	
4. TITLE AND SUBTITLE Nanocrystalline Co-P-SiC Electrocomposite Coating for Replacement of Hard Chrome				5a. CONTRACT NUMBER	
				5b. GRANT NUMBER	
				5c. PROGRAM ELEMENT NUMBER	
6. AUTHOR(S)				5d. PROJECT NUMBER	
				5e. TASK NUMBER	
				5f. WORK UNIT NUMBER	
7. PERFORMING ORGANIZATION NAME(S) AND ADDRESS(ES) U.S. Chrome Corporation,175 Garfield Avenue,Stratford,CT,06615				8. PERFORMING ORGANIZATION REPORT NUMBER	
9. SPONSORING/MONITORING AGENCY NAME(S) AND ADDRESS(ES)				10. SPONSOR/MONITOR'S ACRONYM(S)	
				11. SPONSOR/MONITOR'S REPORT NUMBER(S)	
12. DISTRIBUTION/AVAILABILITY STATEMENT Approved for public release; distribution unlimited					
13. SUPPLEMENTARY NOTES 26th Replacement of Hard Chrome and Cadmium Plating Program Review Meeting, January 24-26, 2006, San Diego, CA. Sponsored by SERDP/ESTCP.					
14. ABSTRACT					
15. SUBJECT TERMS					
16. SECURITY CLASSIFICATION OF:			17. LIMITATION OF ABSTRACT Same as Report (SAR)	18. NUMBER OF PAGES 18	19a. NAME OF RESPONSIBLE PERSON
a. REPORT unclassified	b. ABSTRACT unclassified	c. THIS PAGE unclassified			

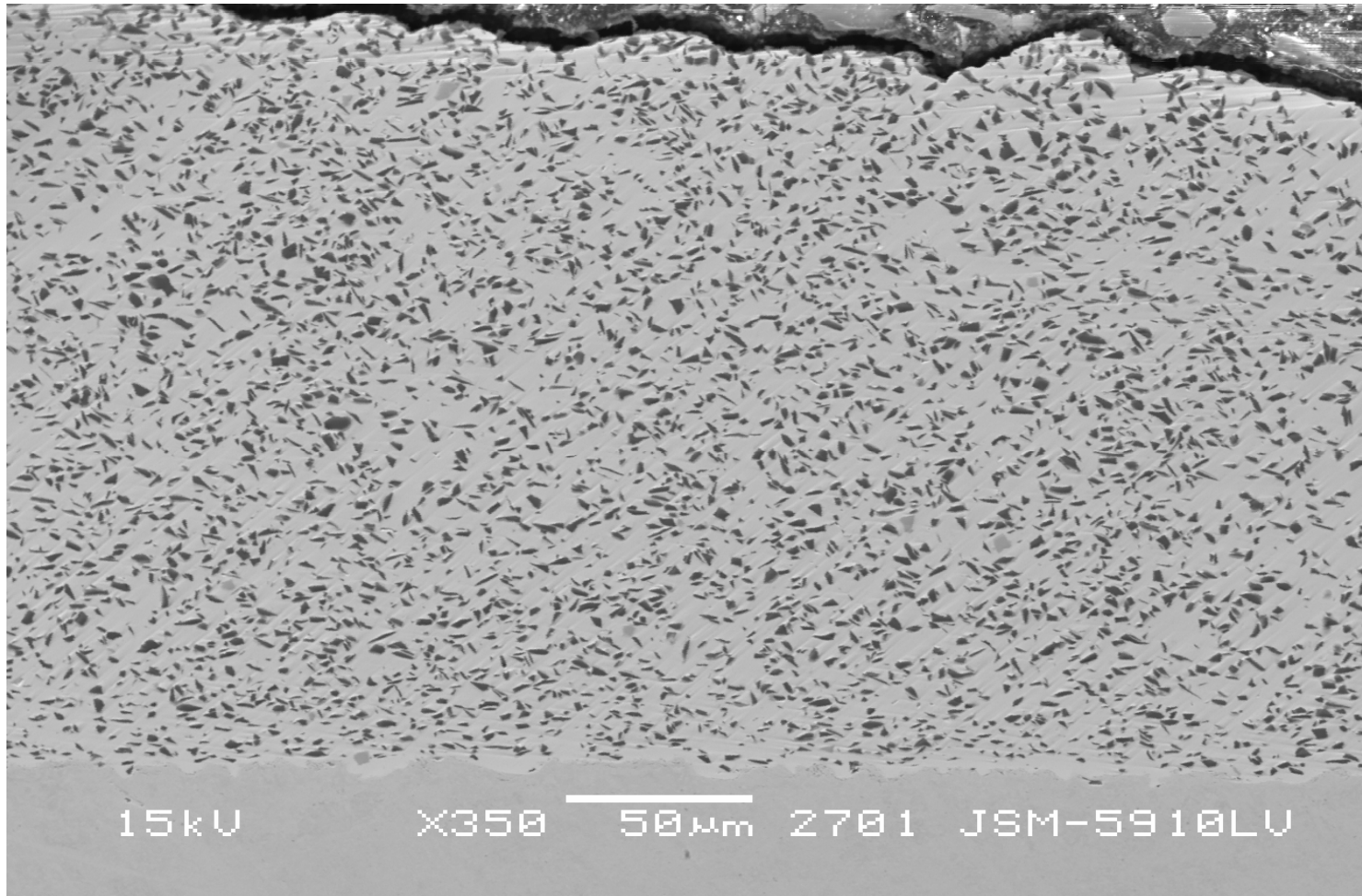
Outline

- **Microstructure and X-ray diffraction**
- **Hardness characteristics**
- **Process control**
- **Corrosion resistance**
- **Wear and friction**
- **Application status**

Microstructure

- **Nanocrystalline Co-P matrix with 20-25 vol.% of 2-5 μ m SiC particles**
- **SiC particles support contact load; very hard SiC particles provide excellent wear properties.**
- **Expected to have excellent tribological performance based on those of a similar Ni-SiC electrocomposite coating of U.S.Chrome**

Microstructure



**Nanocrystalline Co- P matrix containing 2- 5µm SiC particles ;
No cracks or pits as found in hard chrome**

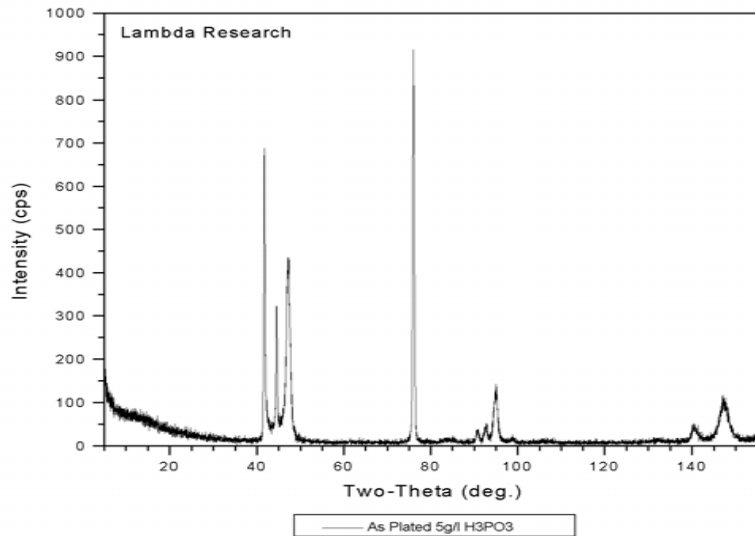
X-ray diffraction results

Wt% P of the coating	Coating structure
4.5	Nanocrystalline
5.6	Nanocrystalline
10.5	Amorphous

**X-ray diffraction analysis performed by
Lambda Technologies, Cincinnati OH.**

X-ray diffraction results

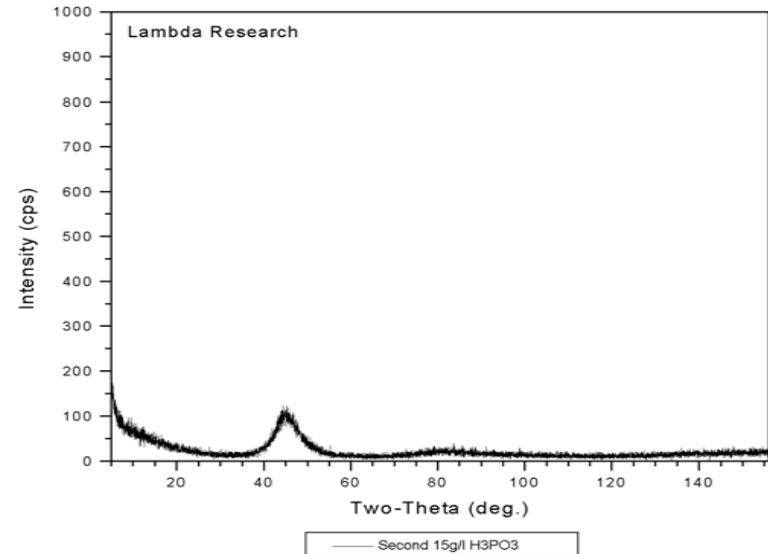
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Coating with 4.5 wt.%P
Nanocrystalline
Grain size 48.4 nm

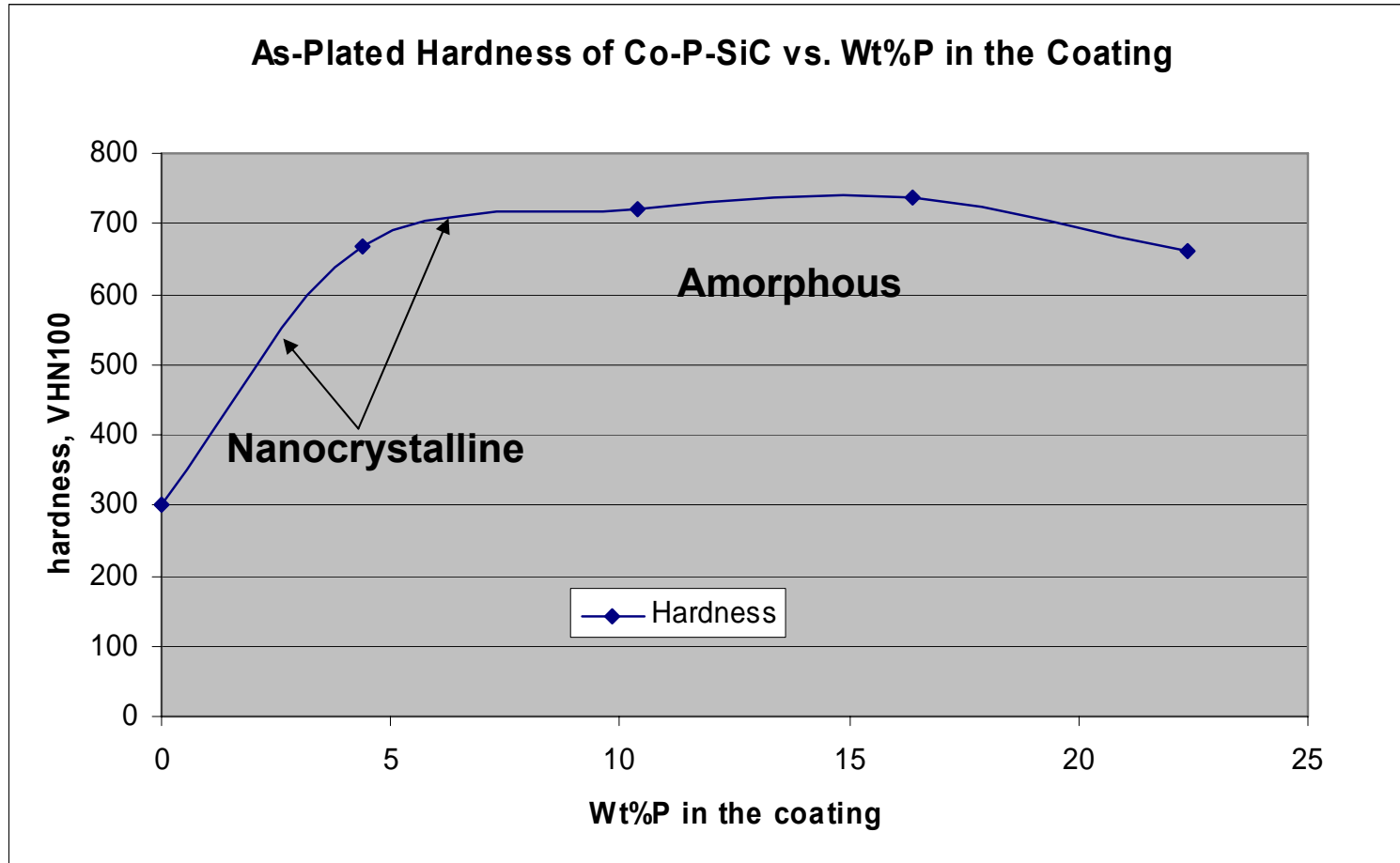
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Coating with 10.5 wt.%P
Amorphous

Hardness characteristics – As-plated Co-P-SiC



Values of phosphorus content > 8 wt.%P were extrapolated from Measured wt.%P vs. bath Phosphorus content linear regression

Hardness characteristics: 5.6 wt.%P Co-P-SiC and Co-P, heat treated at 400°C

Coating	As - plated	As heat treated at 400°C for 1.5hrs	As heat treated at 400°C for 24 hrs
Co - P	635 VHN₁₀₀	1000 VHN₁₀₀	-
Co – P - SiC	653 VHN₁₀₀	1216 VHN₁₀₀	1060 VHN₁₀₀

Increase in hardness resulting from precipitation hardening is appreciably Higher for Co-P-SiC compared to that of Co-P

Hardness characteristics: 5.6 wt.%P Co-P-SiC and Co-P, heat treated at 204°C

Coating	As - plated	As heat treated at 204°C for 1.5hrs	As heat treated at 204°C for 45 hrs
Co - P	635 VHN₁₀₀	688 VHN₁₀₀	630
Co – P - SiC	653 VHN₁₀₀	756 VHN₁₀₀	756 VHN₁₀₀

**Low temperature heat treatment is necessary for certain alloys.
Some hardening is realized even at low temperature. Hardness increase is higher for Co-P-SiC**

Comparison with pulse plated Co-P (Integran Tech. Inc. paper, SUR/FIN,2005)

Feature	Co-P-SiC, DC plated 5.6 wt.% P	Co-P Pulse plated 3 – 5.2 wt.%P
Grain size	48 nm	5- 15 nm
As-plated hardness	650 VHN₁₀₀ for 5.6 wt.%P	800 VHN₁₀₀ for 5.2 wt.%P
400°C HT hardness	1210 VHN₁₀₀ for 5.6 wt.%P	1100 VHN₁₀₀ for 5.2 wt.%P
Variation of as-plated Hardness,3-5.6 wt%P	610 - 650 VHN₁₀₀	700 - 800 VHN₁₀₀
Plating rate	0.005 inch/hr at 2ASI	0.002-0.008 inch/hr depending on ASI
Maximum thickness	Plated up to 0.02 inch	Plated up to 0.04 inch

Process Control

- **Conventional DC plating process; Typical plating rate 0.0025 inch/hr; Can be plated with both consumable and non consumable anodes (Platinized Ti, graphite,..)**
- **Maximum thickness plated so far: 0.01 – 0.02 inch**
- **Nanocrystalline structure and SiC particle incorporation are controlled by key parameters.**
- **Key parameters, such as phosphorus content of the bath, pH, current density, temperature , and their ranges are optimized by Design of Experiments (DOE)**

Process Control (continued)

- **Different analytical methods for Phosphorus content of the bath and coating were evaluated**
- **Both ICP and colorimetric methods are used.**
- **Phosphorous content in the coating was analyzed using colorimetric methods and verified/calibrated using ICP methods.**
- **Bath phosphorus content is controlled by additions to the bath based on chemistry depletion as a function of Amp.hr used, verified by colorimetric methods.**

Corrosion Resistance – ASTM B117

- 0.001” – 0.002” thick 3” x 6” “Q” Panels have exceeded 200 hrs of neutral salt fog exposure with no evidence of red rust.**
- Panels will continue in cabinet until failure, red rust, appears.**
- Chromium performs poorly for corrosion resistance due to cracking/stresses.**

In Progress...

- **Pin-on-disc wear and friction test**
- **Embrittlement test (ASTM-F519)**
- **Further grinding / honing evaluations**

Preliminary comparison with hard chrome

Feature	Nanocrystalline Co-P-SiC	Hard chrome
Plating rate	Up to 0.005” per hr (0.0025”/hr typical)	Up to 0.0016” per hr (0.001”/hr typical)
Thickness	Plated up to 0.02”	Typically < 0.02”
As-plated Condition	Crack free	microcracked
Microstructure	48 nm grains with 2-5µm SiC particles	Normal grain size, >1000nm
Power	DC	DC

Preliminary comparison with hard chrome (continued)

Feature	Nanocrystalline Co-P-SiC	Hard chrome
As-plated hardness	650 VHN ₁₀₀	800 -1200 VHN ₁₀₀
As HT at 200°C	750 VHN ₁₀₀	-
As HT at 400°C	1200 VHN ₁₀₀	-
Thermal stability	400°C	400°C
Bend ductility, 0.003" thick, 90° bend	A few fine cracks at the bend	No visible cracks At the bend
Corrosion	Exceeds 200 hr ASTM B-117	24 hr ASTM B-117

Coating Application Evaluation

- **Coating has been successfully plated onto Ti-6-4, Inconel 718, and Steel with a 0.01 inch thick deposit.**
- **Co-P-SiC coating has been successfully ground to an Ra = 6 μ inch finish**
- **A number of industrial applications, such as IC engine bore, are being pursued**
- **Part of a detailed test program being conducted by Air Force's Materials Lab at WPAFB**

Summary

- **A nanocrystalline Co-P-SiC electrocomposite coating has been developed using conventional direct current electroplating process**
- **The coating exhibits all the desired characteristics which are either superior or equal to those of hard chrome**